

PATENT

Docket No.: M4065.0165/P165

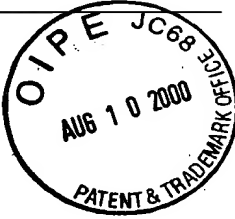
IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:
Garry Mercaldi et al.

Serial No.: 09/285,773

Filed: April 5, 1999

For: METHOD FOR ETCHING
DOPED POLYSILICON WITH
HIGH SELECTIVITY TO
UNDOPED POLYSILICON



Group Art Unit: 1765

Examiner: L. Eronini

Assistant Commissioner for Patents
Washington, D.C. 20231

AMENDMENT

Dear Sir:

In response to the Office Action dated June 7, 2000 (Paper No. 6), please
amend the above-identified U.S. patent application as follows:

IN THE CLAIMS:

Please delete claims 8, 12 and 19-21.

Please amend the following claim:

1. (amended) A composition for selectively etching a doped substance, said
composition consisting essentially of:

1164299 v1; _YDN011.DOC

08/11/2000 SDUONG 00000069 09285773

01 FC:102

234.00 OP

08/18/2000 VAUGHN 00000002 041073 09285773
01 FC:102 156.00 CH

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